OIPE
NOV 17 2003
PATENT & TRADEMARK OFFICE

APPLICANT'S ART CITATION (Use additional sheets if necessary)	Application 09/932,652	OFGS File No. P/3541-14
	Applicant Masayu HIGUCHI	
	Filing Date August 17, 2001	Group Art Unit ~~2851~~ 2615

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date MM-YYYY	Name	Class	Sub-class	Filing Date If Appropriate
	US-					
	US-					
	US-					
	US-					
	US-					
	US-					
	US-					
	US-					
	US-					
	US-					

RECEIVED
NOV 21 2003
Technology Center 2600

FOREIGN PATENT DOCUMENTS

	Document Number	Date MM-YYYY	Country	Class	Sub-class	Translation Yes	Translation No
JP	20000-162679	06-2000	Japan	—	—		✓
JP	2000-134533	05-2000	Japan	—	—	spec., p. 2	
JP	06-121225	04-1994	Japan	—	—		✓

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

JP		Japanese Office Action corresponding to related Japanese Application No. 2000-249653, dated September 17, 2003 and translation thereof.

Examiner [signature] Date Considered 9/4/04

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.

APPLICANT'S ART CITATION (Use several sheets if necessary)	Application 09/932,652	OFGS File No. P/3541-14
	Applicant Masayu HIGUCHI	
	Filing Date	Group Art Unit 2615

JC871 U.S. PTO 09/932652 08/17/01

U.S. PATENT DOCUMENTS

Examiner Initial	Document Number	Date	Name	Class	Sub-class	Filing Date If Appropriate

FOREIGN PATENT DOCUMENTS

	Document Number	Date	Country	Class	Sub-class	Translation Yes	Translation No
4	11-84483	03/26/99	Japan	—	—		X
2	2000-133452	05/12/2000	Japan	—	—		X

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)

Examiner [signature] Date Considered 9/4/04

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP § 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to the applicant.